Electronic Supplementary Information

Experimental section

Materials: NiCl₂· $6H_2O$, CoCl₂· $6H_2O$, NH₄F, and urea were purchased from Beijing Chemical Corp. The RuCl₃· $3H_2O$ and Nafion (5 wt%) were purchased from Sigma-Aldrich Chemical Reagent Co., Ltd. Nitric acid (HNO₃) and ethanol were purchased from Tianjin Chemical Corporation. Carbon cloth (CC) was provided by Hongshan District, Wuhan Instrument Surgical Instruments business, and was pretreated in HNO₃ and then cleaned by sonication in water and ethanol to remove surface impurities. The water used throughout all experiments was purified through a Millipore system.

Preparation of NiCo₂O₄/CC: To prepare the precursor of NiCo₂O₄/CC, NiCl₂·6H₂O (4 mmol), CoCl₂·6H₂O (8 mmol) and urea (15 mmol) were dissolved in 75 mL water under vigorous stirring for 30 min. Then the solution was transferred to a 50 mL Teflon-lined stainless-steel autoclave in which a piece of CC was immersed into the solution. The autoclave was sealed and maintained at 120 °C for 6 h in an electric oven. After the autoclave cooled down to room temperature, the precursor was taken out and washed with water and ethanol for several times, followed by drying at 60 °C for 2 h. To prepare NiCo₂O₄/CC, the precursor was annealed at 450 °C in air for 2 h.

Preparation of NiCo₂O₄@Ni-Co-Ci/CC: The NiCo₂O₄@Ni-Co-Ci/CC was prepared by oxidative polarization of NiCo₂O₄/CC at a constant potential of 0.98 V vs. Ag/AgCl for 2.5 h. Two control samples were prepared by oxidative polarization at 1.08 V for 2.5 h and at 0.98 V for 20 h, respectively. The NiCo₂O₄/CC, Ag/AgCl and graphite plate were used as the working electrode, reference electrode and counter electrode, respectively. And 1.0 M K-Ci (pH: 8.3) was used as electrolyte. The NiCo₂O₄@Ni-Co-Ci loading was determined to be 1.7 mg cm⁻² using a high precision microbalance.

Preparation of RuO₂/CC: RuO₂ was prepared according to reported method.¹ Briefly, 2.61 g RuCl₃·3H₂O and 30 mL NaOH (1.0 M) were added into 100 mL distilled water and stirred for 45 minutes at 100 °C. The precipitates were collected by centrifugation and washed with water for several times, followed by drying at 70 °C. Finally, the product was annealed at 300 °C for 3 h under air atmosphere. RuO₂ ink was prepared by dispersing 20 mg of RuO₂ powder into 490 μ L of water/ethanol (v/v = 1:1) solvent containing 10 μ L of 5 wt% Nafion and sonicated for 30 min. Then the RuO₂ ink was coated onto a bare CC of 0.25 cm⁻².

Characterizations: The X-ray diffraction (XRD) patterns were collected by RigakuD/MAX 2550 diffractometer with Cu K α radiation ($\lambda = 1.5418$ Å). The scanning electron microscopy (SEM) images were taken by a Hitachi S-4800 field emission scanning electron microscope at an accelerating voltage of 20 kV. The high-resolution transmission electron microscopy (HRTEM) measurements were performed on a Hitachi H-8100 electron microscopy with an accelerating voltage of 200 kV. The XPS scans were collected with a Thermal ESCALAB 250 spectrometer using Mg as the exciting source.

Electrochemical measurements: Electrochemical measurements were performed with a CHI 660E electrochemical analyzer (CH Instruments, Inc., Shanghai) in a standard three-electrode system. NiCo₂O₄@Ni-Co-Ci/CC was used as the working electrode. A graphite plate and an Ag/AgCl electrode were used as the counter electrode and the reference electrode, respectively. The current densities were calculated with respect to the geometrical area of the electrodes (0.5 cm × 0.5 cm). The reference electrode was calibrated to the reversible hydrogen electrode (RHE) scale in all measurements using the following equation: E (RHE) = E (Ag/AgCl) + (0.197 + 0.059 pH) V. For Linear sweep voltammetry (LSV) measurements, the scan rate was set to be 5 mV s⁻¹. All experiments were carried out at 25 °C.



Fig. S1. Scanning electron microscopy images for the precursor of $NiCo_2O_4/CC$.



Fig. S2. XRD patterns of two control samples. Red curve: $NiCo_2O_4/CC$ treated by oxidative polarization at 1.08 V for 2.5 h. Blue curve: $NiCo_2O_4/CC$ treated by oxidative polarization at 0.98 V for 20 h.



Fig. S3. The Nyquist plots for NiCo₂O₄@Ni-Co-Ci/CC and NiCo₂O₄/CC in 1.0 M K-Ci. These plots were collected at 0.85V (vs. Ag/AgCl) with a frequency range from 100000 to 0.1 Hz and an amplitude of 5 mV.



Fig. S4. Cyclic voltammograms collected at various scan rates (10, 25, 50, 75 and 100 mV s⁻¹) for (a) NiCo₂O₄@Ni-Co-Ci/CC and (c) NiCo₂O₄/CC in 1.0 M K-Ci. The difference (Δj) between capacitive currents as a function of scan rates for (b) NiCo₂O₄@Ni-Co-Ci/CC and (d) NiCo₂O₄/CC in 1.0 M K-Ci. The slope is twice of double layer capacitance.



Fig. S5. SEM images of NiCo₂O₄@Ni-Co-Ci/CC after CV test.



Fig. S6. XPS spectra of NiCo₂O₄@Ni-Co-Ci after CV test in the (a) Ni 2p, (b) Co 2p,

⁽c) C 1s and (d) O 1s regions.



Fig. S7. Multi-current process of NiCo₂O₄@Ni-Co-Ci/CC. The current density started at 4 mA cm⁻² and ended at 40 mA cm⁻², with an increment of 4 mA cm⁻² per 300 s without iR correction.



Fig. S8. Practically generated and theoretically calculated oxygen amount versus time for NiCo₂O₄@Ni-Co-Ci/CC in 1.0 M K-Ci.

Catalyst	j (mA cm ⁻²)	η (mV)	Electrolyte	Ref.
NiCo ₂ O ₄ @Ni- Co-Ci/CC	10	507	0.2 M K-Ci	This work
	20	608	0.2 M K-Ci	
	20	503	0.5 M K-Ci	
	20	337	1.0 M K-Ci	
Fe-Ci/FTO	10	560	0.2 M Ci	2
Fe-Bi/ITO	10	600	0.5 M BBS	3
Co-Pi NA/Ti	10	450	0.1 M K-Pi	4
Co-Ci/GC	9.1	~771	0.2 M K-Ci	5
CoP@Co-Bi-Pi/Ti	10	410	0.1 M K-Bi	6
Fe-Co ₃ O ₄ @Fe-	10	420	0.1 M K-Bi	7
	1.0	10.0	0.1.N.W.D.	
Co-Ni LDH/FTO	1.0	490	0.1 M K-P1	8
NiO _x -Cat/GC	1.15	~604	0.2 M K-Ci	9
Ni-Bi film/FTO	1.0	390	0.5 M K-Bi	10
Ni-Bi film/FTO	1.0	413	1.0 M K-Bi	11
Ni-Bi film/FTO	0.6	618	0.1 M Na-Bi	12
NiO _x -en/FTO	1.0	510	0.6 M Na-Bi	13
NiO _x -Bi	1.0	650	0.5 M K-Bi	14
Ni-Bi/CC	10	470	0.1 M K-Bi	15
Ni-4Gly	1.0	480	0.25 M PBS	16
CuO/FTO	0.1	430	0.1 M K-Bi	17
Cu-Bi/FTO	1.0	~525	0.2 M Na-Bi	18

Table S1. Comparison of catalytic performance for $NiCo_2O_4$ @Ni-Co-Ci/CC withother reported non-noble-metal electrocatalysts under benign conditions.

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